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6. ☐ Interview Summary (Paper No./Mail Date 7. ☑ Examiner's Amendm 8. ☐ Examiner's Statemen 9. ☐ Other	ent/Comment Int of Reasons for Allowance
	on the cover sheet with the correction (REMAINS) CLOSED in this application is subject to IMPEP 1308. 3. 2006. 35 U.S.C. § 119(a)-(d) or (f). In received. In received in Application No ents have been received in this received in this received. Note the attached EXAMINER's ason(s) why the oath or declarate submitted. Patent Drawing Review (PTO-Section of the drawing received of the drawing received of the drawing received of the submitted. Patent Drawing Review (PTO-Section of the drawing received of the drawing rec

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EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

- 2. The application has been amended as follows: in claim 14, "claim 10" has been changed to –claim 13–.
- 3. Claims 1, 3-9, and 11-15 are in condition for allowance.
- 4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Davis D. Hwu whose telephone number is 571-272-4904. The examiner can normally be reached on 8:00-4:30. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Dave Scherbel can be reached on 571-272-4919. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DAVIS HWU PRIMARY EXAMINER

Davis Hwu